Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	2423	430/322.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:56
S2	68	chemical\$4 same amplify same resist	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:02
S3	59	S2 and develop\$4	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:02
S4	5103	brewster same angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:04
S5	5730	430/270.1.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:37
S11	243	S1 and S5	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:14
S12	1766	chemical\$4 same amplified same positive same resist	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:16
S13	21	irradiat\$4 same expos\$3 same light same brewster same angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/12 14:55
S14	11810	thickness same reduction same ratio	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 14:20
S15	14795	onium same salt	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:50
S16	15920	acid same generator	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:23

S17	2600	S15 and S16	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 11:24
S18	5730	430/270.1.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 14:29
S19	3858	S18 and @ay<"2003"	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 14:29
S20	2423	430/322.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 14:30
S21	1675	S20 and @ay<"2003"	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/06 14:30
S22	· 2424	430/322.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 08:55
S23	5108	brewster same angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 16:26
S24	11817	thickness same reduction same ratio	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:46
S25	17	S23 and S24	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:47
S26	8	S23 same S24	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:31
S28	2424	430/322.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:48
S29	3	S28 and S23	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:49

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S31	1770	chemical\$4 same amplified same positive same resist	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:50
S32	14807	onium same salt	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:50
S33	109	S32 same S31	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:51
S34	15951	acid same generator	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:51
S35	597	S31 same S34	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/10 14:51
S36	68	chemical\$4 same amplify same resist	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:57
S37	5108	brewster same angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:57
S38	21	irradiat\$4 same expos\$3 same light same brewster same angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 17:00
S39	11817	thickness same reduction same ratio	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:57
S40	1	S38 same S39	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:58
S41	1	S38 and S39	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 09:58
S42	1	("6861209").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/10/11 15:10

S43	76	protect\$4 same group same S39	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON .	2006/10/11 15:10
S44	5108	brewster same angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 16:26
S45	4674	brewster adj angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 17:00
S46	20	irradiat\$4 same expos\$3 same light same brewster adj angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/11 17:00
S47	1	("6660455").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR .	OFF	2006/10/12 10:05
S48	1	("6703190").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/10/12 11:05
S49	4686	brewster\$4 adj angle	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/12 14:07
S50	795185	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/12 14:02
S51	580	S49 and S50	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/12 14:02
S52	3578	brewster\$4 adj angle and @ay<"2003"	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/13 12:08
S55	766	brewster\$4 adj angle.ab.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/13 12:09
S56	795185	photoresist or resist or photosensitive	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/13 12:09

S57	38	S55 and S56	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/13 15:42
S58	22624	thick\$4 adj reduc\$4	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/13 15:35
S60	3578	brewster\$4 adj angle and @ay<"2003"	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/13 15:36
S66	1	("6479210").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2006/10/13 16:32
S67	504	Endo adj Masayuki.in.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/18 10:20
S68	267	Sasago adj Masaru.in.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	ON	2006/10/18 10:20